Thank you very much for your interest in traveling to the U.S. to participate in a standards development activity.

While the U.S. visa application process is significantly different than the process in many other countries, we very much hope that you will be able to obtain a visa to come to the U.S. successfully. The following guidance is intended to help you to more clearly understand the process for application.

Step One: Be informed

We urge you to carefully review all the information on local procedures for non-immigrant visa application provided by the U.S. Embassy or Consulate General for your home region. Following are links to this information in English and, where available, Chinese: Beijing, Chengdu, Guangzhou, Shanghai, Shenyang.

Please remember that your application must be submitted through the U.S. Embassy or Consulate General that has jurisdiction over your place of residence.

Where should I apply? 我应该在哪里申请?

Access the electronic DS-156 form. This must be completed and submitted electronically.

Step Two: Apply Early

Due to potentially long wait times for a visa interview and possible requirements for additional clearances, applicants are encouraged to begin the visa application process as early as possible – ideally 90 days in advance of the intended travel.

Waiting times for a visa interview can range from a few days to two months, depending on location and time of year. Find the current average wait times in your region: Beijing, Chengdu, Guangzhou, Shanghai, Shenyang. Some technical experts engaged in certain sensitive scientific or technical fields may be subject to additional processing procedures which can add an additional 30 days of to the visa application procedures. Learn more about these procedures.

Step Three: Be Prepared

Please follow all instructions provided on the website for your local U.S. Embassy or Consulate General website to avoid costly delays

Applicants for U.S. visas should come to the visa interview with a thorough understanding of their travel plans and logistics, and should be prepared to demonstrate strong ties to China. Please follow these links for more information English 中文.

Step Four: Inform Us of Problems as Early as Possible

Should you encounter any problems in the visa application process, please contact ANSI as soon as possible. Neither ANSI nor the issuer of your invitation letter has the authority to influence consular decisions. However, we may be able to advise you on additional steps you may be able to take, or otherwise be of assistance.

Contact for ISO: Mr. Tony Zertuche isot@ansi.org; +212-642-4961 (U.S.)
Contact for IEC: Ms. Debbie Negron dnegron@ansi.org; +212-642-4936 (U.S.)